

# Chemicals contained in products

## Package-type

Epson Package name; **SON2-16PIN**

JEITA Package name; **P-VSON16-04.40x05.30-0.65**

Lead frame plating; **Lead(Pb) Free**

Weight; **0.05 [g]** \*Note1

Part	Subpart	Subpart weight [mg]	Substance name	CAS No.	Content ※2		Application
					[mg]	[ppm]	
IC Die	IC Die	1.9	Silicon	7440-21-3	1.9	999894	Base material
			Boron	7440-42-8	0.000004	2	Dopant
			Phosphorus	7723-14-0	0.00001	5	Dopant
			Aluminum	7429-90-5	0.00004	20	Metalization
			Arsenic *Note3	7440-38-2	0.00001	5	Dopant
			Fluorine *Note3	7782-41-4	0.000004	2	Dopant
			Titanium *Note3	7440-32-6	0.00004	20	Metalization
			Molybdenum *Note3	7439-98-7	0.00004	20	Metalization
			Tungsten *Note3	7440-33-7	0.00006	30	Metalization
			Cobalt *Note3	7440-48-4	0.000004	2	Metalization
	Stress buffer coat	0.037	Polyimide	-	0.037	1000000	Stress buffer coat *Note4
Package	Die Bonding material	0.24	Silver	7440-22-4	0.20	826087	Base material
			Epoxy resin	-	0.021	86957	Adhesive
			Phenol resin	-	0.021	86957	Adhesive
	Lead Frame Plating	0.092	Tin	7440-31-5	0.090	975000	Solder
			Silver	7440-22-4	0.002	25000	Solder
	Lead Frame	17	Copper	7440-50-8	16.1	945000	Conductor
			Silver	7440-22-4	0.085	5000	Inner lead plating
			Others *Note5	-	0.85	50000	Additive
	Bonding Wire	0.22	Gold	7440-57-5	0.22	1000000	Conductor
	Mold resin	31	Epoxy resin	-	1.5	50000	Base material
			Antimony Trioxide	1309-64-4	0.46	15000	Flame retardant
			Halogenated compound(Brominations epoxy)	-	0.46	15000	Flame retardant
			Silica	60676-86-0/-	24.6	806000	Filler
			Carbon black	1333-86-4	0.092	3000	Coloring agent
			Hardening chemical(ex:Phenol resin)	-	3.4	110000	Hardening chemical
			Organic phosphorous compound	-	0.031	1000	Hardening accelerator

Regarding the information of chemical substances

\*Note1 The weight might be somewhat different depending on an individual built-in IC-chip specification like the size etc.

\*Note2 Content data are estimated values based on supplier information and intended levels of content in product.

Actual measurements may vary from these values somewhat.

\*Note3 Use or not-use of these substances depends on individual built-in IC-chip specification.

\*Note4 The stress buffer coat may not be used depending on the individual model.

\*Note5 The nickel, zinc, tin, silicon, iron, and the zinc oxide are included for the Cu type. And the carbon, silicon, and manganese are included for 42alloy type.